

ABSTRACT

According to the present invention, there are provided
an insulating film for an organic EL element, which has
5 sufficiently low water permeability and a good sectional form
and whose reactivity with a basic material and an electrode
made from a metal having a low work function is suppressed,
an insulating film for an organic EL element, which enables
the formation of a through hole or U-shaped cavity therein
10 and has excellent flattening performance, high transparency
and high resistance to a resist stripper, and a radiation
sensitive resin composition for forming the insulating film.

An organic EL display element having this insulating
film is free from an emission failure and has sufficiently
15 long luminance half-life period and excellent reliability.

The above composition comprises an alkali-soluble resin
which may have an epoxy group and a 1,2-quinonediazide
compound.